

Vacuum Etching Technology still gaining ground

As announced ahead of last year's Productronica in Munich, the Vacuum Etching Technology again attracted the most attention on the booth. Presented for the first time as a impressive innovation three years ago, this technology can now look back on years of testing which have proven its allround fitness. Its use under manufacturing conditions has fully satisfied expectations when it comes to reliability, precision and quality. It therefore comes as no surprise that this innovation, first presented in 2001, turned out to be a much admired, proven high-end etching technology this year. These was a line of PP, designed for acid etching solutions – yet this technology has also been proved to be excellently suited for use on alkaline etchants and for photochemical milling parts.





While the way it works was continuously demonstrated in a video specially made for this purpose, all who were interested had the opportunity to clarify details for themselves with the product itself, and to discuss their problems with the specialists.



With the increasing buoyancy of the economy in recent months, there were definite signs of rising demand for this new technology with its convincing results - a trend which continued throughout the show and was confirmed by another new order directly after the fair ended.

achieved as well. Already widely used in the USA, this cleaning procedure is now being increasingly applied in Europe. Interested visitors had an opportunity to get detailed information on this concept at several lectures held at the Productronica Arenas.



Moreover, last year, the new co-operation with the Zestron® division of Dr. O.K.Wack Chemie GmbH, Ingolstadt was reported. Zestron® is a leading manufacturer of cleaning agents, which, taking advantage of the PILL decades of experience in the construction of plant for horizontal conveyorized wet cleaning line, contributed to the creation of a perfect in-line cleaning system for electronic components using water-based cleaning agents. This system cuts costs appreciably from a medium number of units on. Thanks to short contact periods, a higher level of compatibility is achieved as well. Already widely used in the USA, this cleaning procedure is now being increasingly applied in Europe. Interested visitors had an opportunity to get detailed information on this concept at several lectures held at the Productronica Arenas.